

## Supporting information

### **Observation of surface species in plasma-catalytic dry reforming of methane in a novel atmospheric pressure dielectric barrier discharge *in situ* IR cell**

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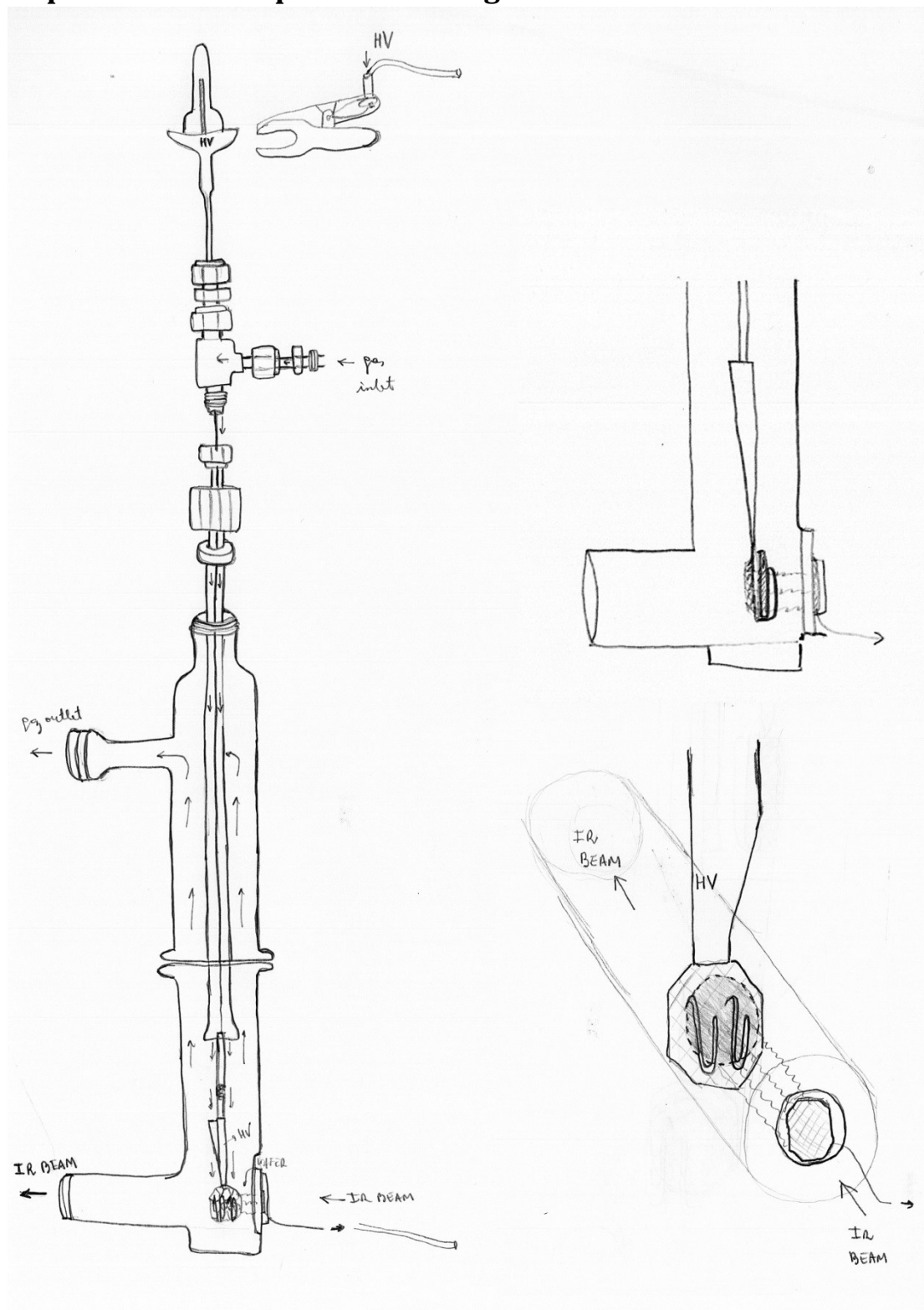
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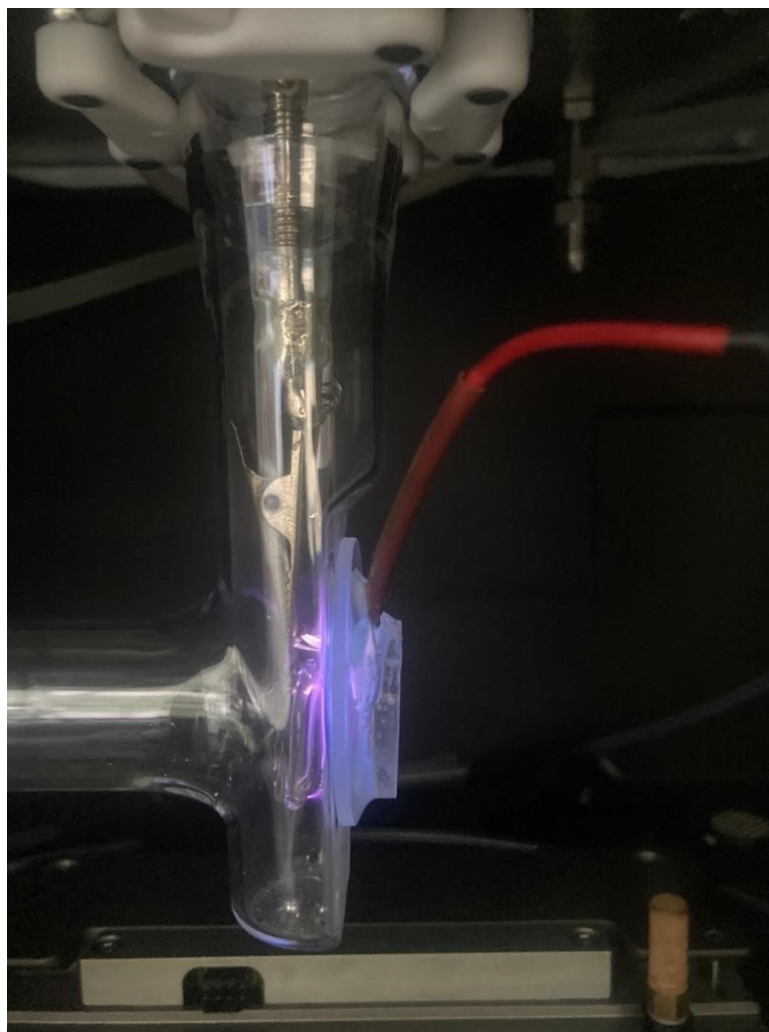
## S1. Experimental setup: additional figures



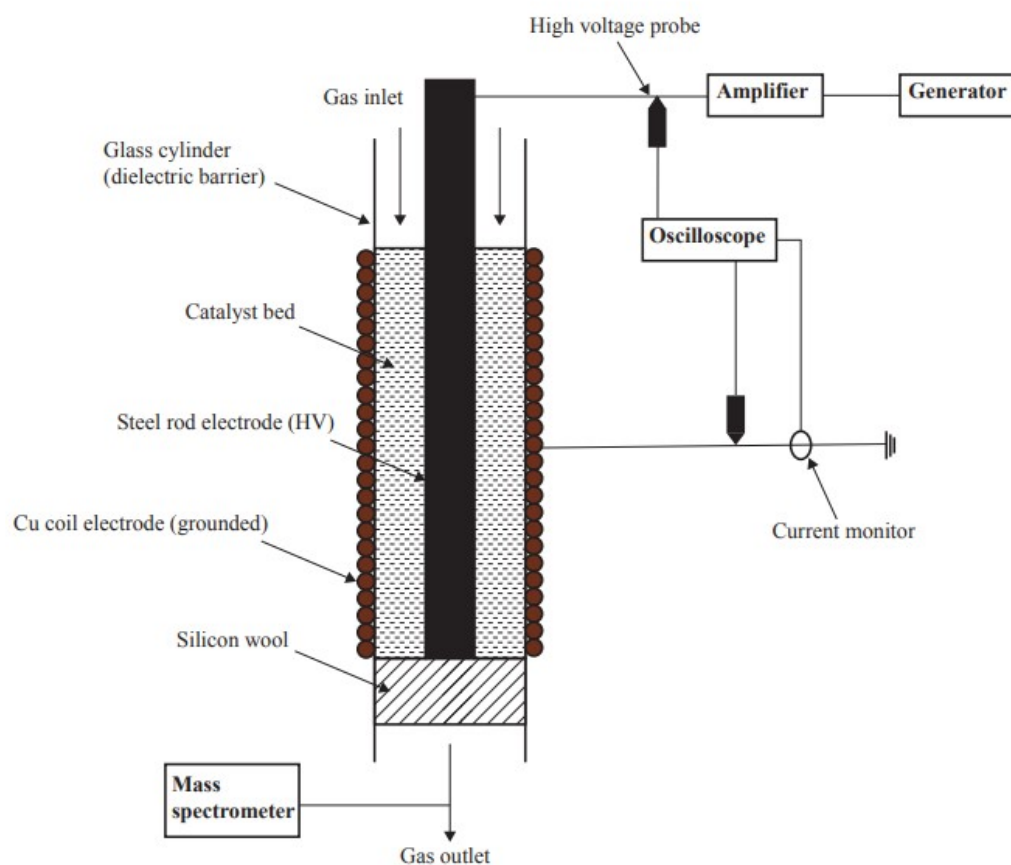
**Figure S1:** Scheme of the plasma *in-situ* DBD IR cell



**Figure S2:** Photograph of the *in-situ* DBD IR cell



**Figure S3:** Photograph of the *in-situ* DBD IR cell with Ar plasma



**Figure S4:** Schematic representation of the packed bed DBD reactor

## S2. Formulas for the calculation of CO<sub>2</sub> and CH<sub>4</sub> conversion and CO, H<sub>2</sub> and C<sub>2</sub>H<sub>4</sub> selectivity and yield

The MS data from the packed bed experiments was collected using PV MassSpec software and was exported for the calculation of CO<sub>2</sub> and CH<sub>4</sub> conversion (equation S1 and S2, respectively), CO selectivity (equation S3) and yield (equation S6), H<sub>2</sub> selectivity (equation S4) and yield (equation S7) and C<sub>2</sub>H<sub>4</sub> selectivity (equation S5) and yield (equation S8). Note that the specific energy input (SEI), and thus the energy cost or energy efficiency of the reaction could not be calculated, as no capacitor was present in the electrical circuit and therefore no Lissajous plots were available for the calculation of the plasma power. However, this was not the focus of our study.

$$\chi_{CO_2}(\%) = \frac{\dot{n}_{CO_2, in} - \dot{n}_{CO_2, out}}{\dot{n}_{CO_2, in}} \cdot 100 \% \quad (\text{eq.S1})$$

$$\chi_{CH_4}(\%) = \frac{\dot{n}_{CH_4, in} - \dot{n}_{CH_4, out}}{\dot{n}_{CH_4, in}} \cdot 100 \% \quad (\text{eq.S2})$$

$$S_{C,CO}(\%) = \frac{\dot{n}_{CO, out}}{(\dot{n}_{CH_4, in} - \dot{n}_{CH_4, out}) + (\dot{n}_{CO_2, in} - \dot{n}_{CO_2, out})} \cdot 100 \% \quad (\text{eq.S3})$$

$$S_{H,H_2}(\%) = \frac{\dot{n}_{H_2, out}}{2 \cdot (\dot{n}_{CH_4, in} - \dot{n}_{CH_4, out})} \cdot 100 \% \quad (\text{eq.S4})$$

$$S_{C,C_2H_4}(\%) = \frac{2 \cdot \dot{n}_{C_2H_4, out}}{(\dot{n}_{CH_4, in} - \dot{n}_{CH_4, out}) + (\dot{n}_{CO_2, in} - \dot{n}_{CO_2, out})} \cdot 100 \% \quad (\text{eq.S5})$$

$$Y_{C,CO}(\%) = \frac{\dot{n}_{CO, out}}{\dot{n}_{CO_2, in} + \dot{n}_{CH_4, in}} \cdot 100 \% \quad (\text{eq.S6})$$

$$Y_{H,H_2}(\%) = \frac{\dot{n}_{H_2, out}}{2 \cdot \dot{n}_{CH_4, in}} \cdot 100 \% \quad (\text{eq.S7})$$

$$Y_{C,C_2H_4}(\%) = \frac{2 \cdot \dot{n}_{C_2H_4, out}}{\dot{n}_{CO_2, in} + \dot{n}_{CH_4, in}} \cdot 100 \% \quad (\text{eq.S8})$$

With  $\dot{n}_i$  the molar flow rate of species i.

### S3. DBD packed bed experiments: calibration curves

In this section, the calibration curves used for calculation of CO<sub>2</sub> and CH<sub>4</sub> conversion and CO, H<sub>2</sub> and C<sub>2</sub>H<sub>4</sub> selectivity and yield, using the formulas given in section S2, are given. The C<sub>2</sub>H<sub>4</sub> concentration was calibrated using FTIR, while the CO<sub>2</sub>, H<sub>2</sub>, CO and CH<sub>4</sub> concentrations were calibrated using MS. In order to account for the contribution of CO<sub>2</sub> to the m/z = 28 signal, to avoid an underestimation of CO production, CO<sub>2</sub> was also calibrated using the m/z = 28 signal (see Figure S10).

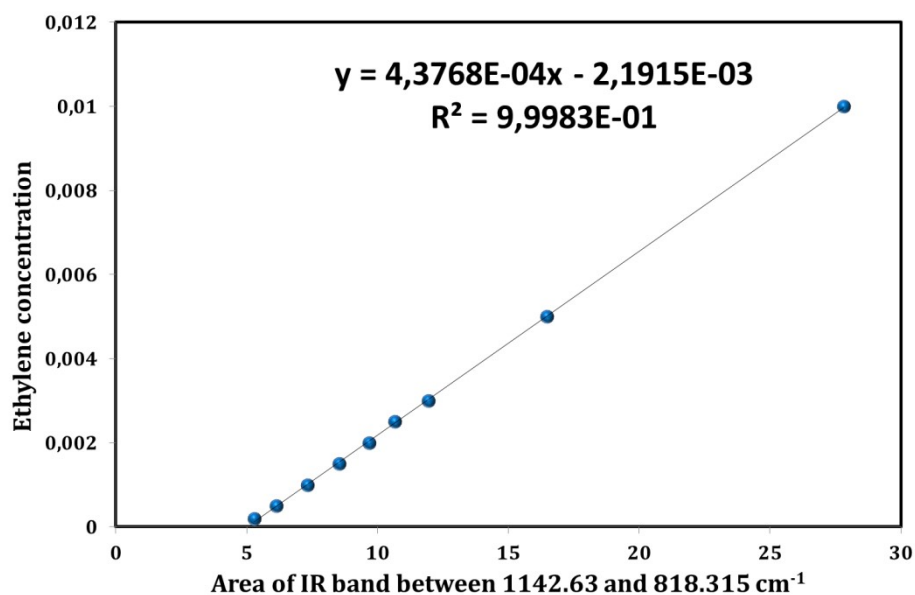


Figure S5: Ethylene calibration curve by FTIR

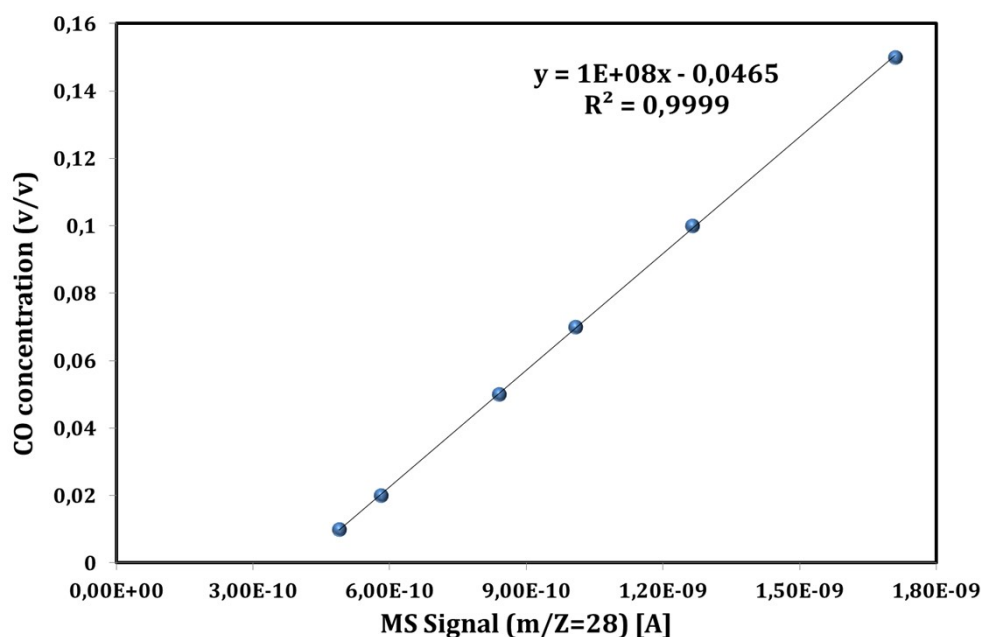


Figure S6: CO calibration curve by MS



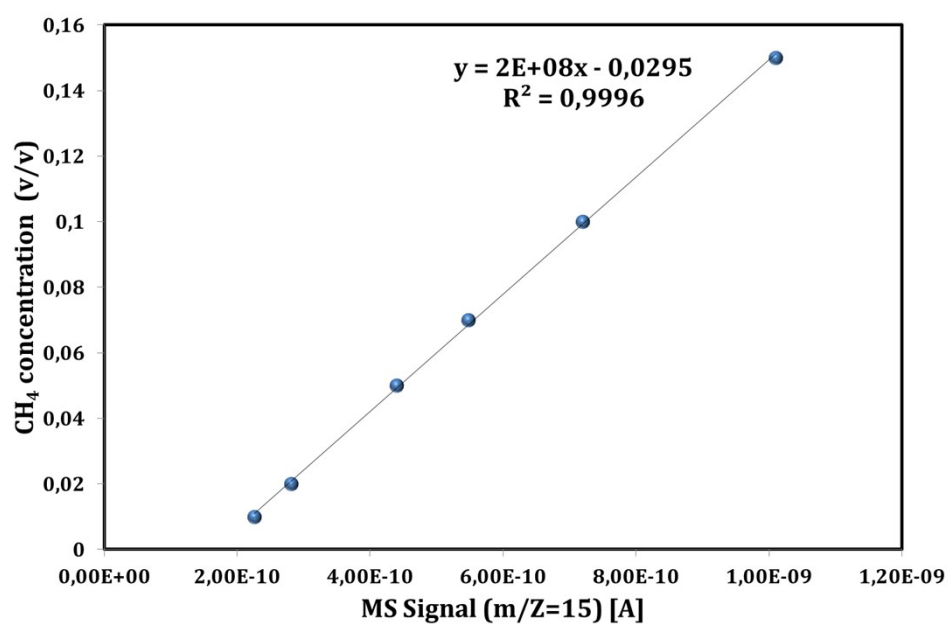


Figure S7: CH<sub>4</sub> calibration curve by MS

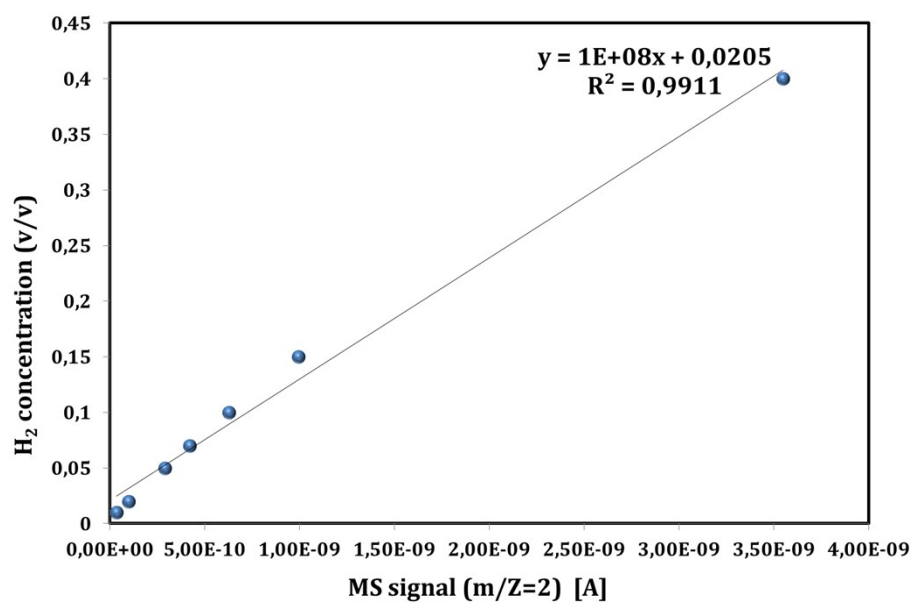


Figure S8: H<sub>2</sub> calibration curve by MS

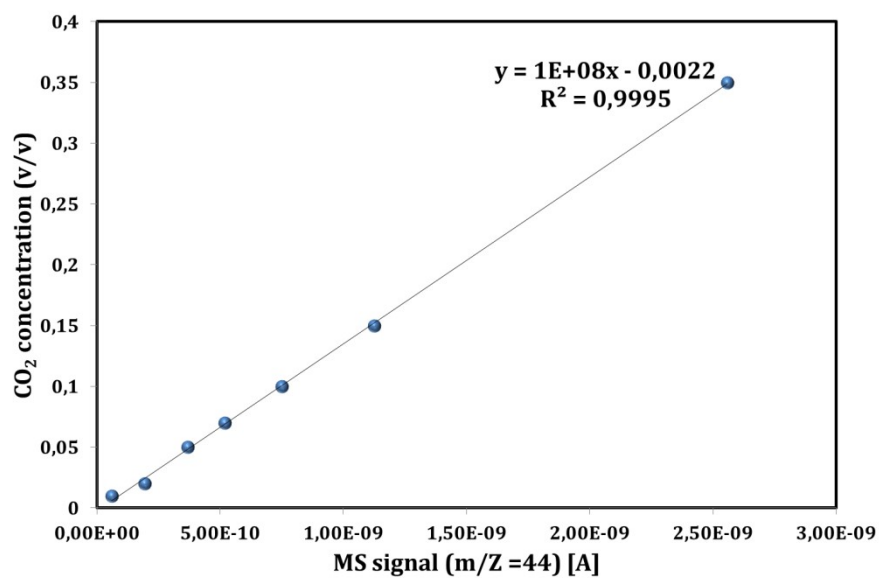


Figure S9: CO<sub>2</sub> calibration curve by MS

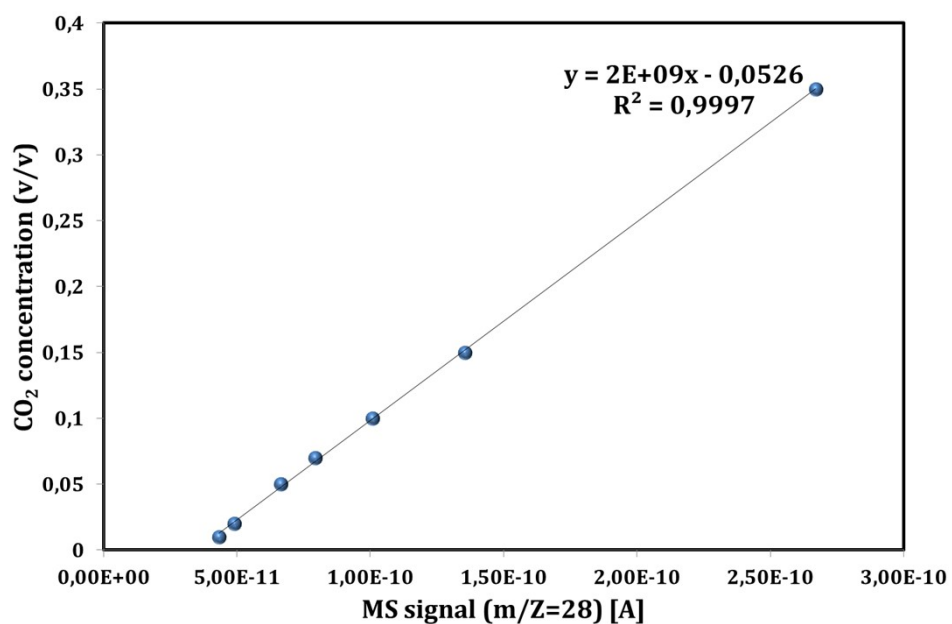
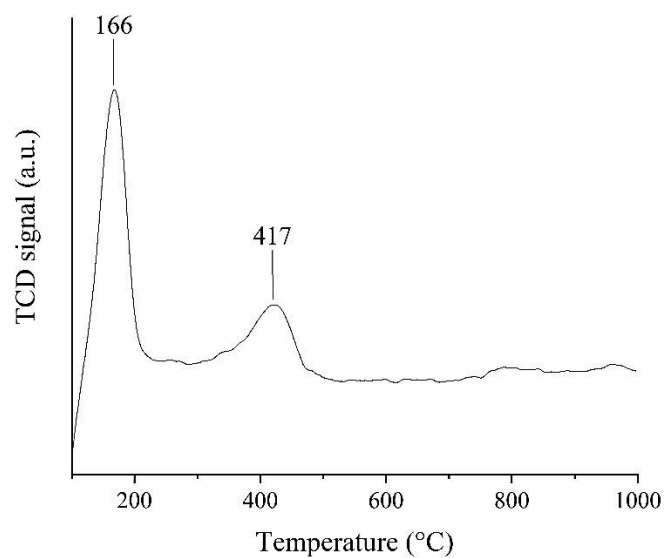


Figure S10: Contribution of CO<sub>2</sub> on the m/Z=28 MS signal

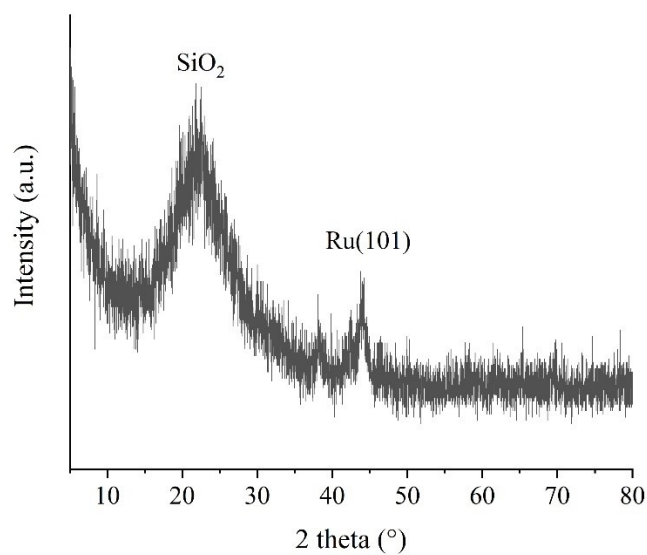
## S4. Catalyst characterization

### S4.1 H<sub>2</sub>-TPR



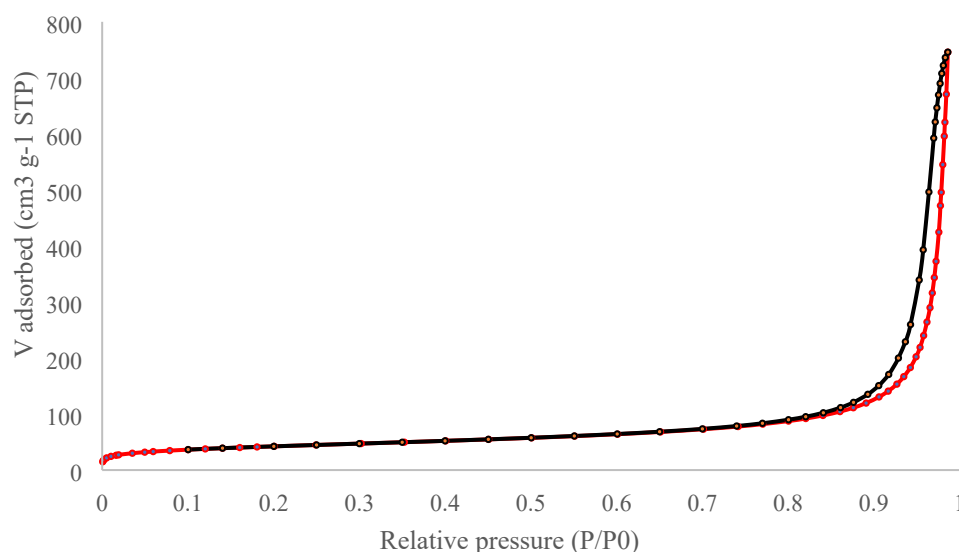
**Figure S11:** H<sub>2</sub>-TPR profile of 3 wt% Ru/SiO<sub>2</sub>

### S4.2 X-ray diffraction

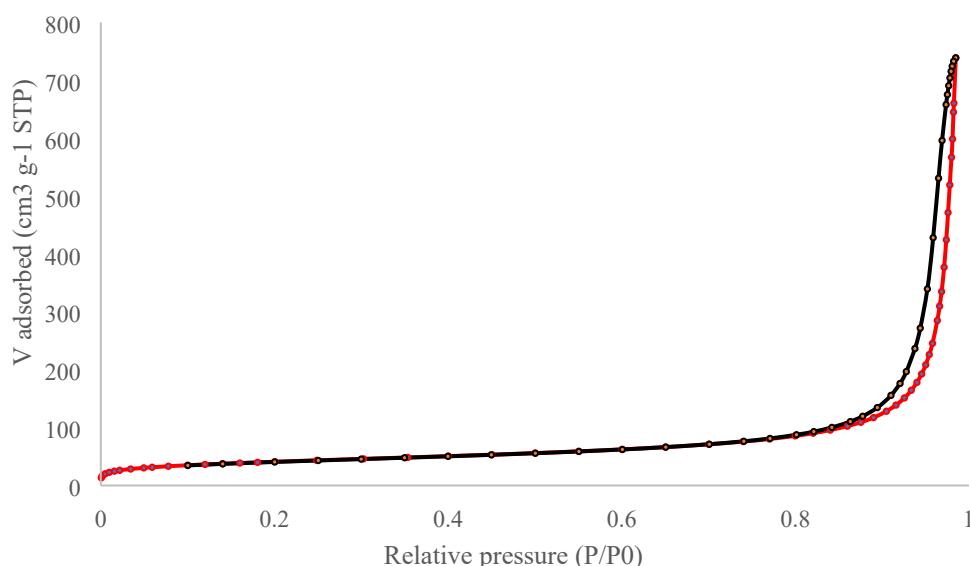


**Figure S12:** XRD diffractogram of 3 wt% Ru/SiO<sub>2</sub>

### S4.3 N<sub>2</sub>-sorption



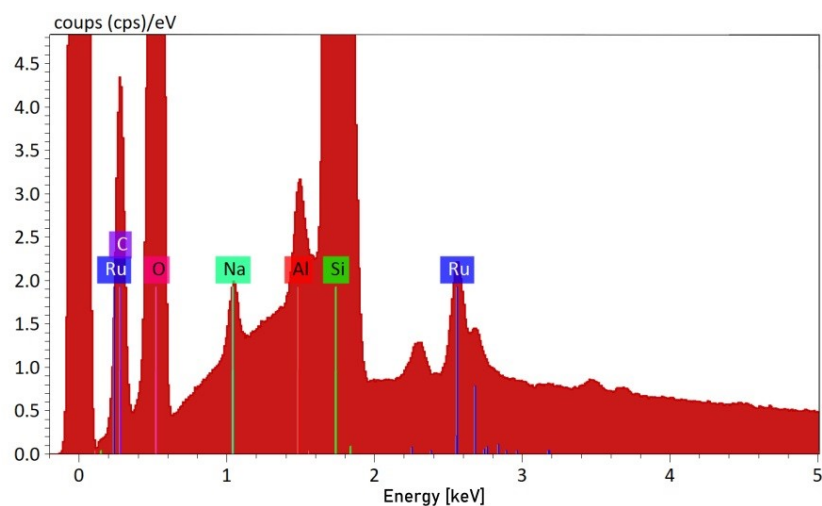
**Figure S13:** N<sub>2</sub>-sorption isotherm of the SiO<sub>2</sub> support, showing adsorption in red and desorption in black



**Figure S14:** N<sub>2</sub>-sorption isotherm of the 3 wt% Ru/SiO<sub>2</sub> sample, showing adsorption in red and desorption in black

### S4.4 EDS-SEM

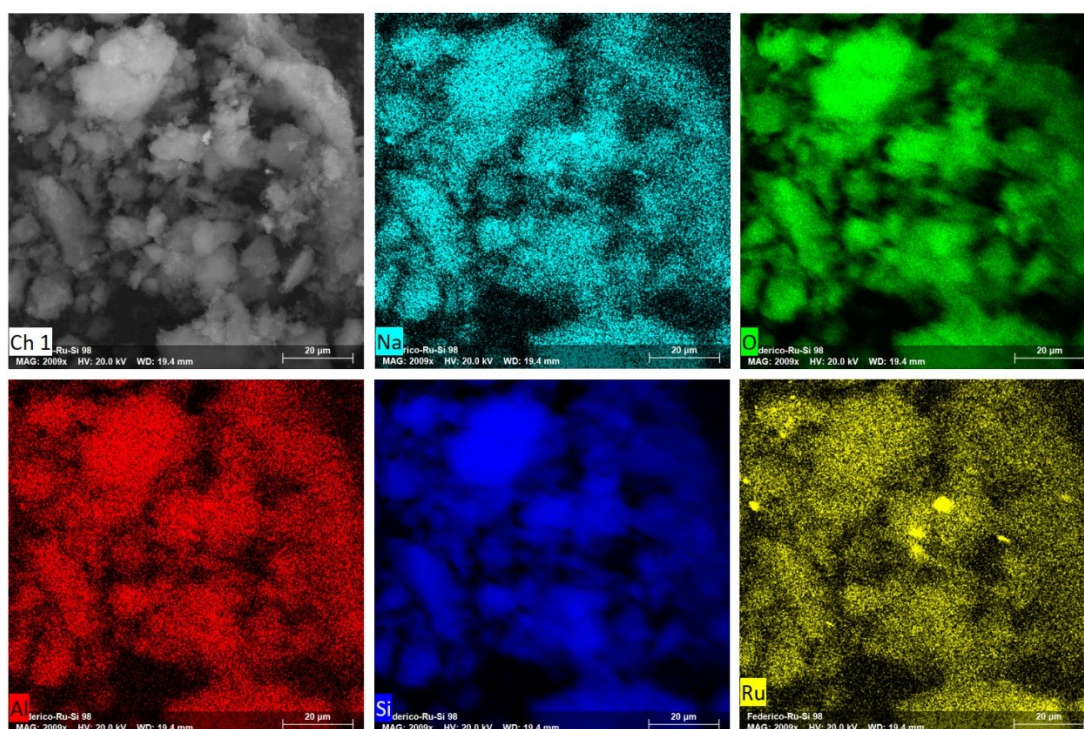
Energy-dispersive X-ray spectroscopy (EDS) coupled to SEM was used for the elemental analysis of Ru/SiO<sub>2</sub> catalyst using an EDAX XM2-30T apparatus. Two separate regions of the catalyst were analyzed. The elemental analysis verified the presence of Na, Al, Si, O and Ru, as shown in Figure S15, with the presence of Al and Na possibly being due to impurities in the SiO<sub>2</sub> support. The carbon is due to the sample holder. The quantification of the main elements is shown in Table S1. The amount of Ru found with this semi-quantitative technique was 4.64 and 5.44 wt% for the region 1 and 2, respectively. These values are both higher than the expected one (3wt%Ru), possibly due to the presence of Ru clusters and the quantitative limitation of this technique. Elemental mapping is shown in Figure S16 and the linear EDS analysis of a Ru cluster is presented in Figure S17.



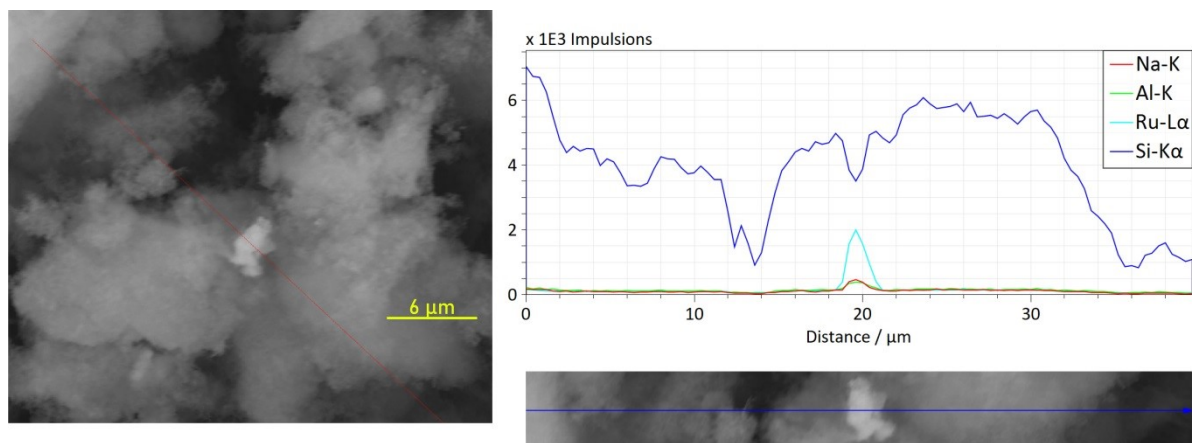
**Figure S15:** Energy-dispersive X-ray spectroscopy of the Ru/SiO<sub>2</sub> catalyst

**Table S1:** Quantification of the elemental analysis of Ru/SiO<sub>2</sub> by EDS in the two measured regions

Element	Region 1		Region 2	
	% mass.	% atom.	% mass.	% atom.
Na	0.78	0.99	1.47	1.87
Al	1.03	1.11	1.15	1.24
Si	93.55	96.57	91.93	95.32
<b>Ru</b>	<b>4.64</b>	<b>1.33</b>	<b>5.44</b>	<b>1.57</b>



**Figure S16:** EDS elemental mapping of the Ru/SiO<sub>2</sub> catalyst showing the mapping of Na, O, Al, Si and Ru



**Figure S17:** Linear EDS analysis of Ru cluster

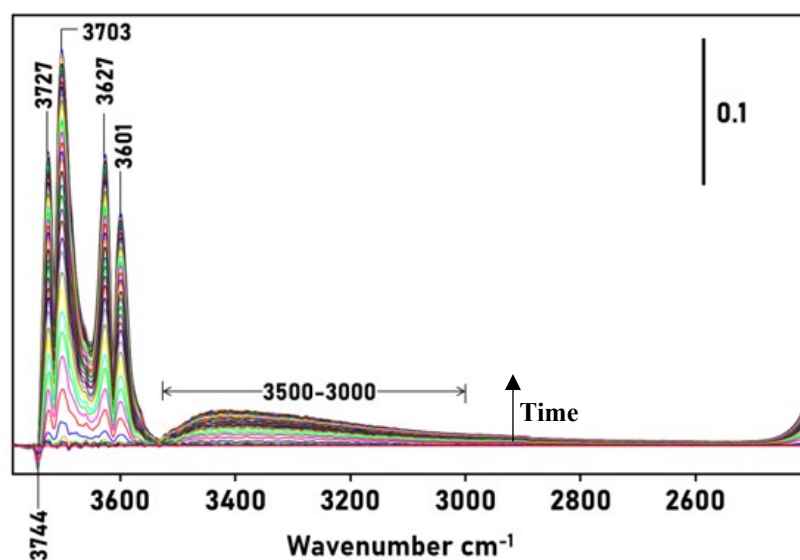
## S5. *In-situ* FTIR in plasma

### S5.1 SiO<sub>2</sub> support

In order to disentangle the effects of the individual reactants in DRM (i.e. CO<sub>2</sub> and CH<sub>4</sub>), we performed experiments with CO<sub>2</sub>/Ar and CH<sub>4</sub>/Ar plasma in addition to experiments with a mixture of the reactants. The experimental procedures are slightly different from the procedures used for DRM, and are discussed, along with presenting the experimental results, in section S5.1.1. and section S5.1.2., for CO<sub>2</sub>/Ar and CH<sub>4</sub>/Ar, respectively.

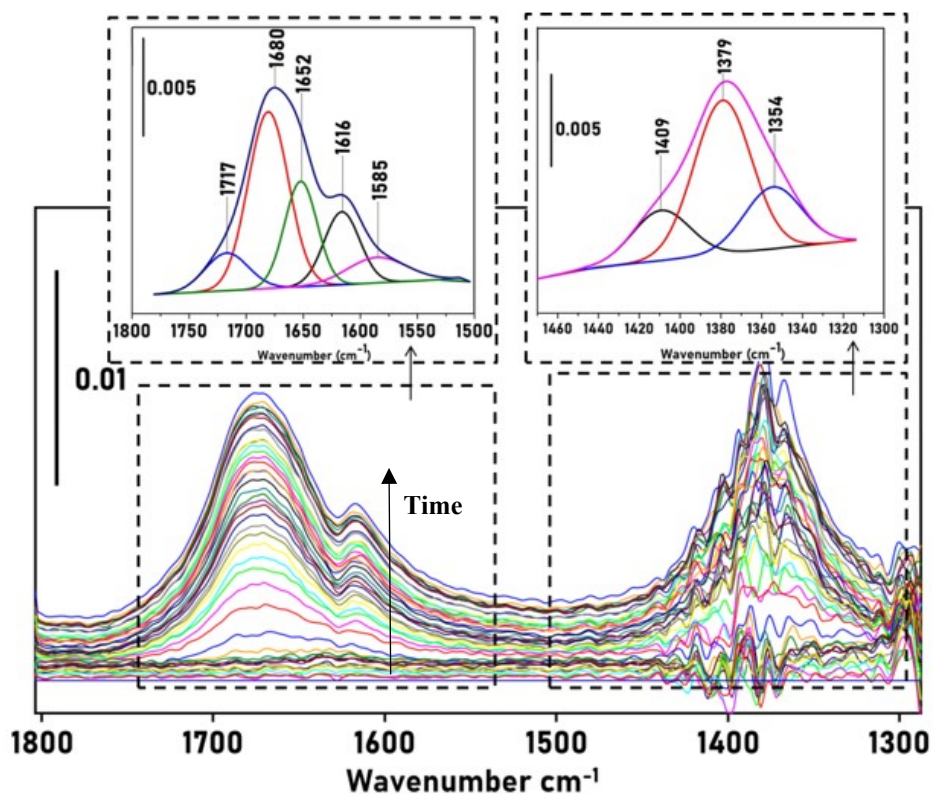
#### S5.1.1. CO<sub>2</sub>/Ar

First, the SiO<sub>2</sub> wafer was introduced into the cell and the catalyst was activated at 350 °C for 3 h under secondary vacuum (10<sup>-7</sup> Torr). Then, the SiO<sub>2</sub> sample was exposed to a mixture of 7 mL min<sup>-1</sup> (STP) CO<sub>2</sub> and 13 mL min<sup>-1</sup> (STP) Ar to monitor CO<sub>2</sub> adsorption on the SiO<sub>2</sub> support before ignition of the plasma. Subsequently, the plasma was ignited at a voltage of ~ 30 kV and a frequency of 3 kHz. Upon stabilization of the spectra, the plasma was extinguished.

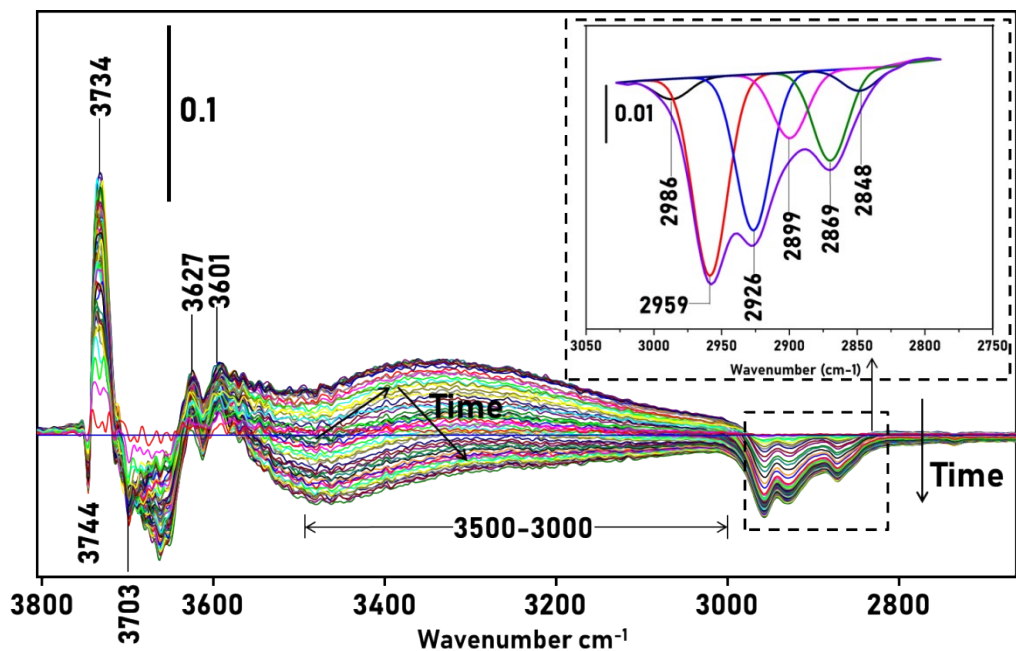


**Figure S18:** FTIR difference spectra of the SiO<sub>2</sub> support exposed to CO<sub>2</sub>/Ar before plasma ignition in the 3800-2400 cm<sup>-1</sup> region as a function of time



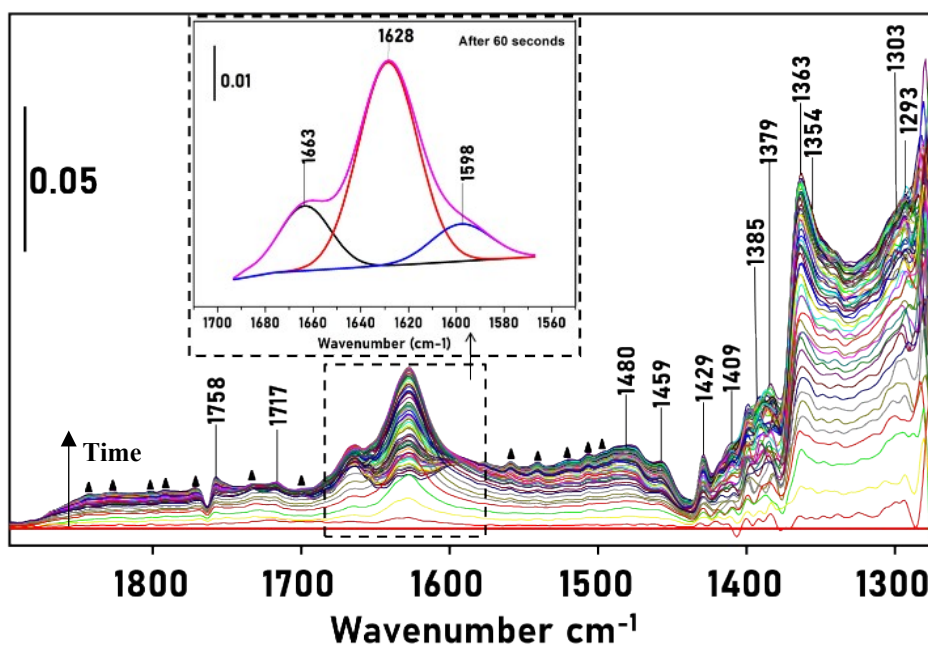


**Figure S19:** FTIR difference spectra of the SiO<sub>2</sub> support exposed to CO<sub>2</sub>/Ar before plasma ignition in the 1800-1300 cm<sup>-1</sup> region as a function of time with details of the 1800-1500 and 1480-1300 cm<sup>-1</sup> regions



**Figure S20:** FTIR difference spectra of the SiO<sub>2</sub> support exposed to CO<sub>2</sub>/Ar plasma in the 3800-2600 cm<sup>-1</sup> region as a function of time with detail of the 3050-2750 cm<sup>-1</sup> region

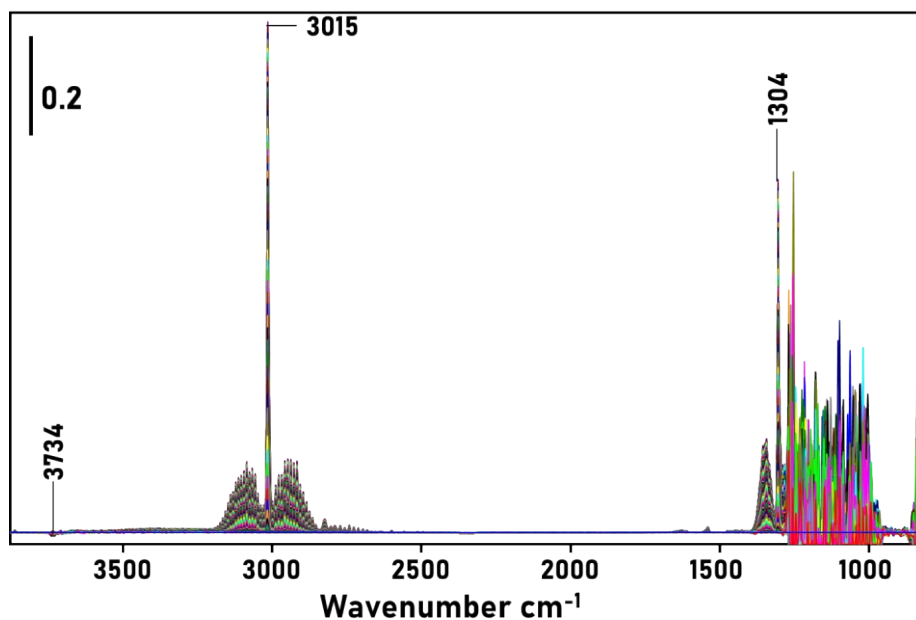




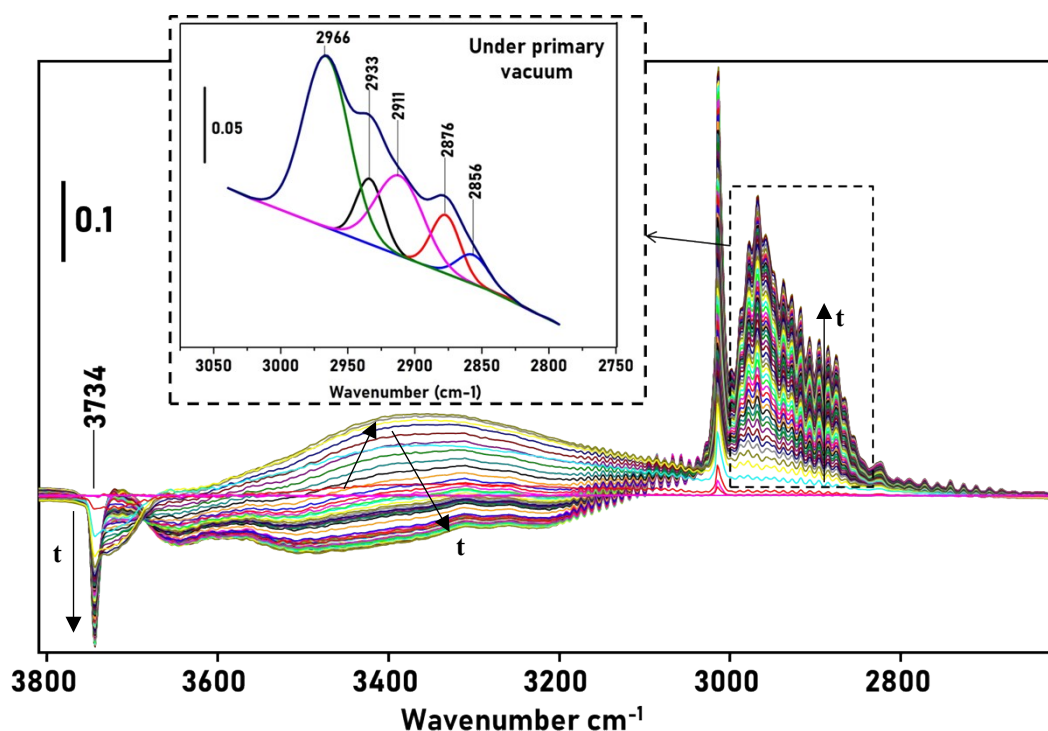
**Figure S21:** FTIR difference spectra of the SiO<sub>2</sub> support exposed to a CO<sub>2</sub>/Ar plasma in the 1900-1275 cm<sup>-1</sup> region as a function of time with detail of the 1710-1550 cm<sup>-1</sup> region; (▲) indicates bands corresponding to H<sub>2</sub>O vapor

#### S5.1.2. CH<sub>4</sub>/Ar

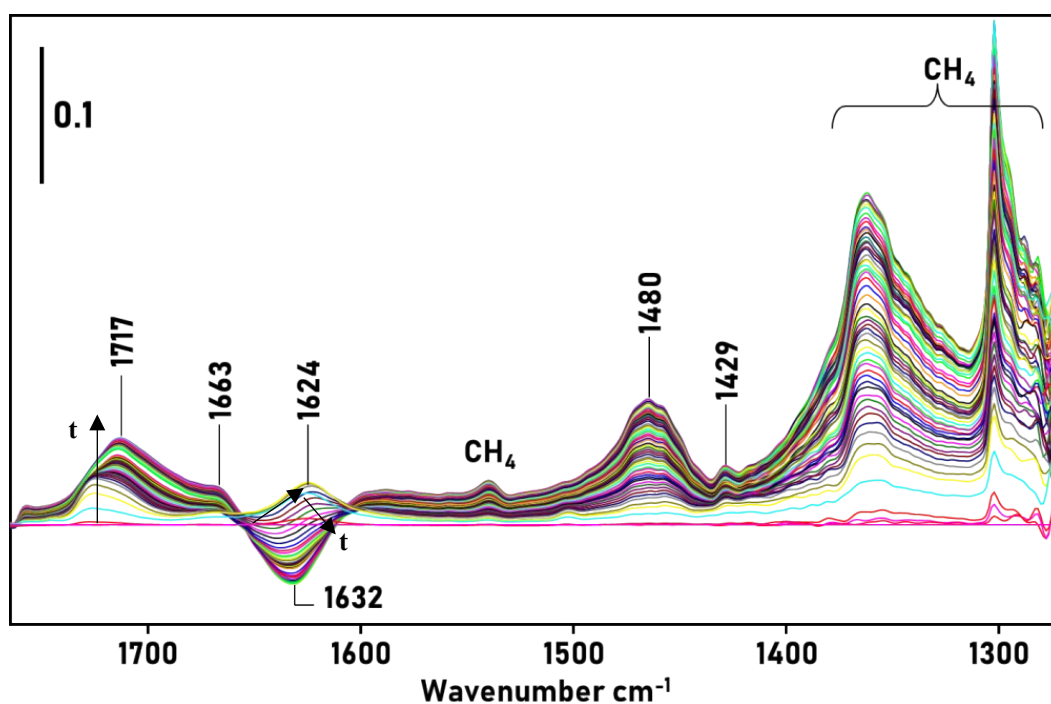
The procedure described in section S5.1.1 was again used for the SiO<sub>2</sub> support, with a gas composition of 7 mL min<sup>-1</sup> (STP) CH<sub>4</sub> and 13 mL min<sup>-1</sup> (STP) Ar.



**Figure S22:** FTIR difference spectra of the SiO<sub>2</sub> support exposed to CH<sub>4</sub>/Ar before plasma ignition in the 3900-800 cm<sup>-1</sup> region as a function of time



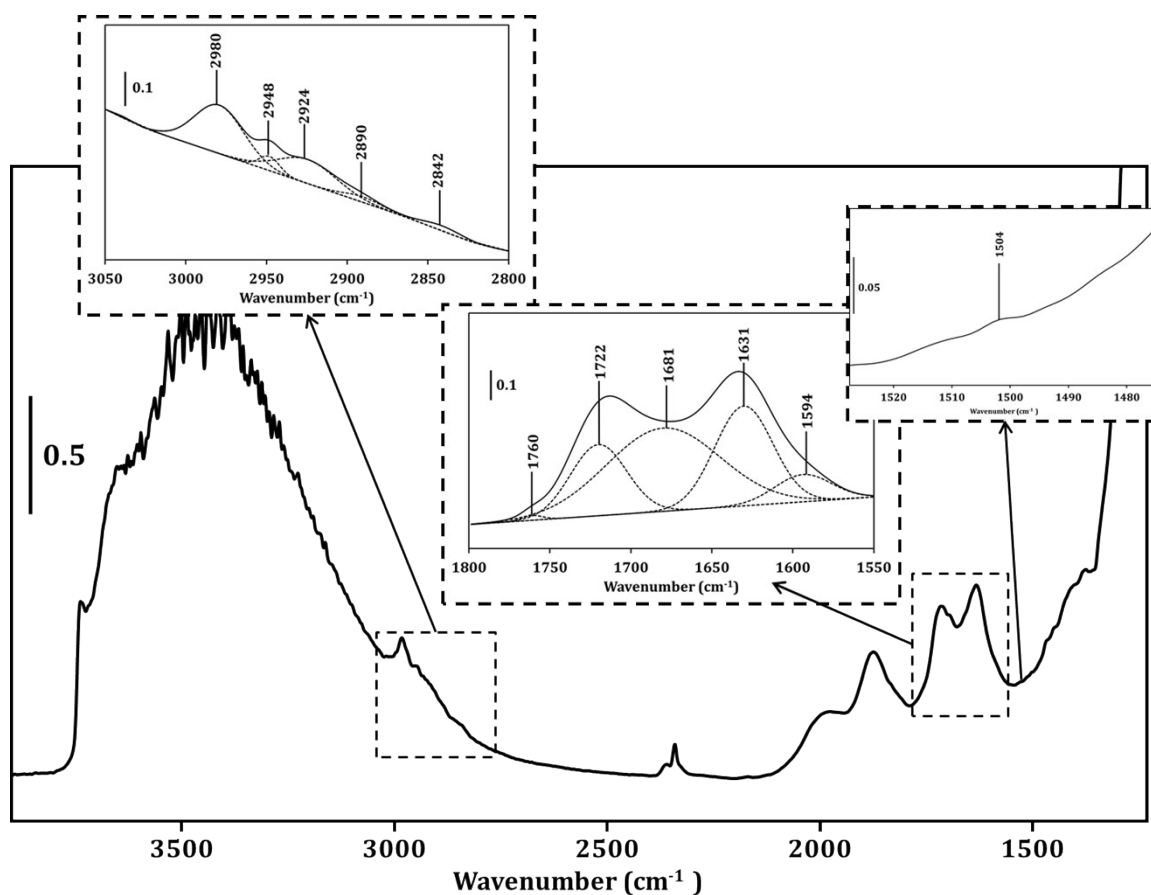
**Figure S23:** FTIR difference spectra of the SiO<sub>2</sub> support exposed to a CH<sub>4</sub>/Ar plasma in the 3800-2600 cm<sup>-1</sup> region as a function of time with detail of the 3075-2750 cm<sup>-1</sup> region under primary vacuum



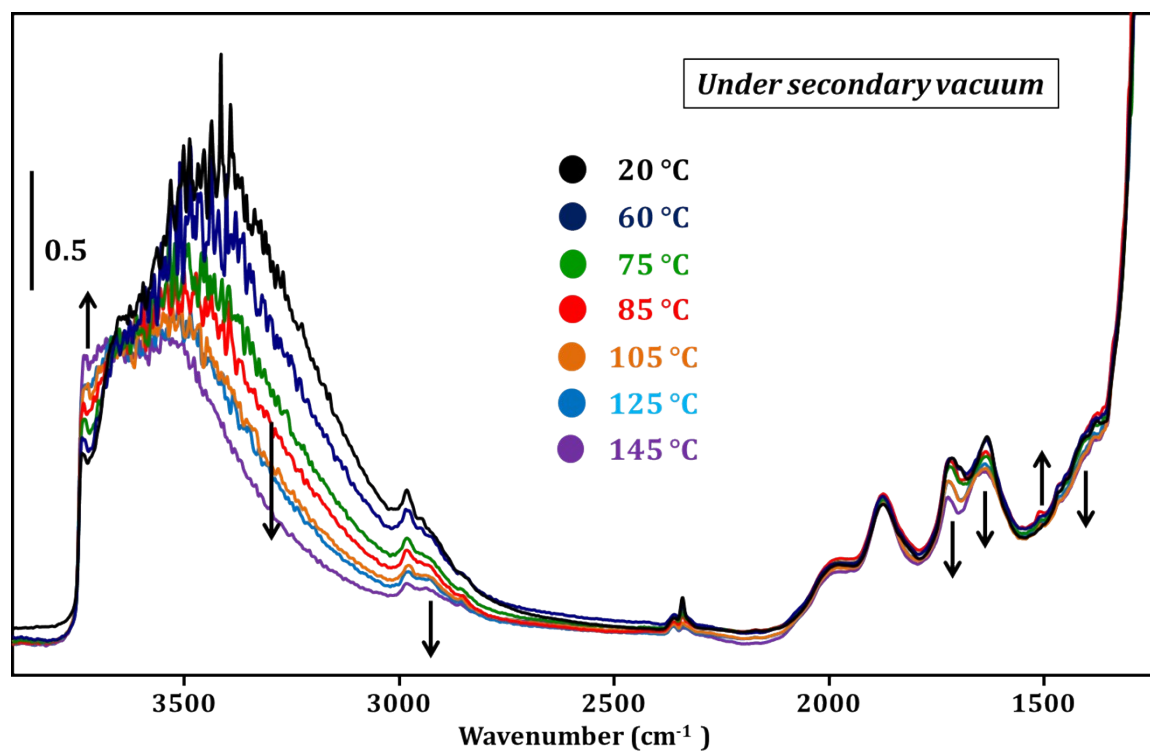
**Figure S24:** FTIR difference spectra of the SiO<sub>2</sub> support exposed to a CH<sub>4</sub>/Ar plasma in the 1760-1275 cm<sup>-1</sup> region as a function of time

### S5.1.3. Dry reforming of methane (DRM)

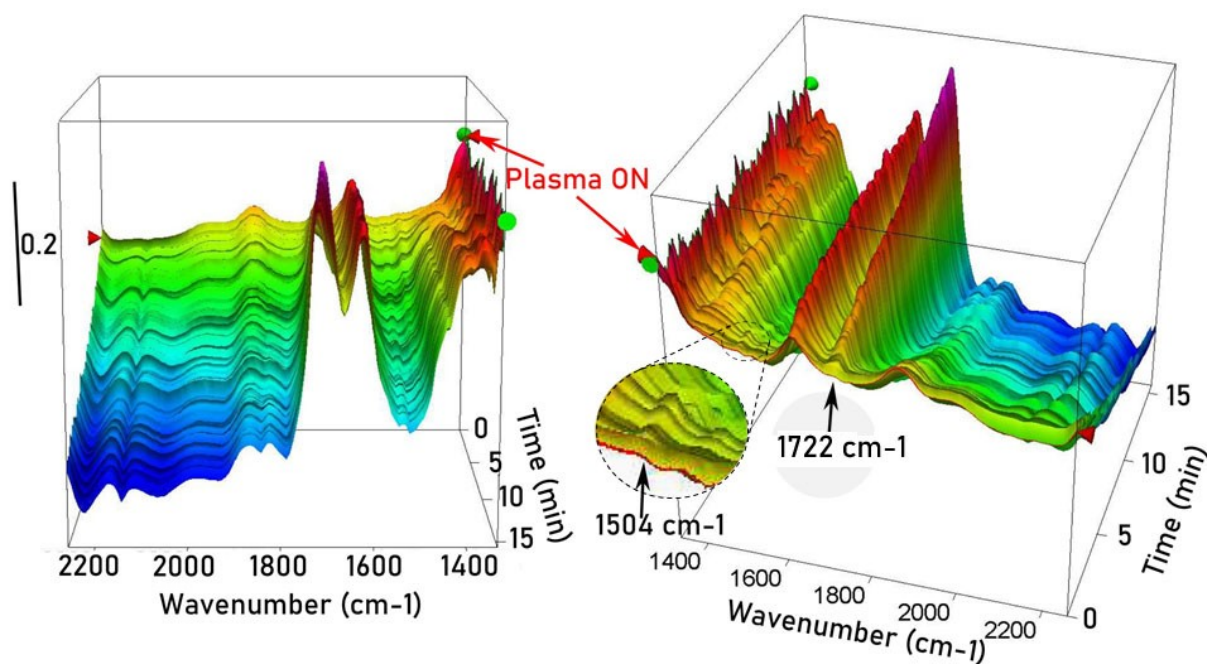
For the DRM experiments, the procedure as described in section 2.2.2 in the main paper was used. Below, relevant results which are referenced in the main paper, and complementary to the results presented there, are shown.



**Figure S25:** FTIR difference spectra of the SiO<sub>2</sub> support under secondary vacuum after exposure to CO<sub>2</sub>/CH<sub>4</sub>/Ar plasma in the 4000-1250 cm<sup>-1</sup> region



**Figure S26:** FTIR difference spectra of the SiO<sub>2</sub> support after exposure to CO<sub>2</sub>/CH<sub>4</sub>/Ar plasma under secondary vacuum exposed to increasing temperatures (20 – 145 °C) in the 4000-1250 cm<sup>-1</sup> region



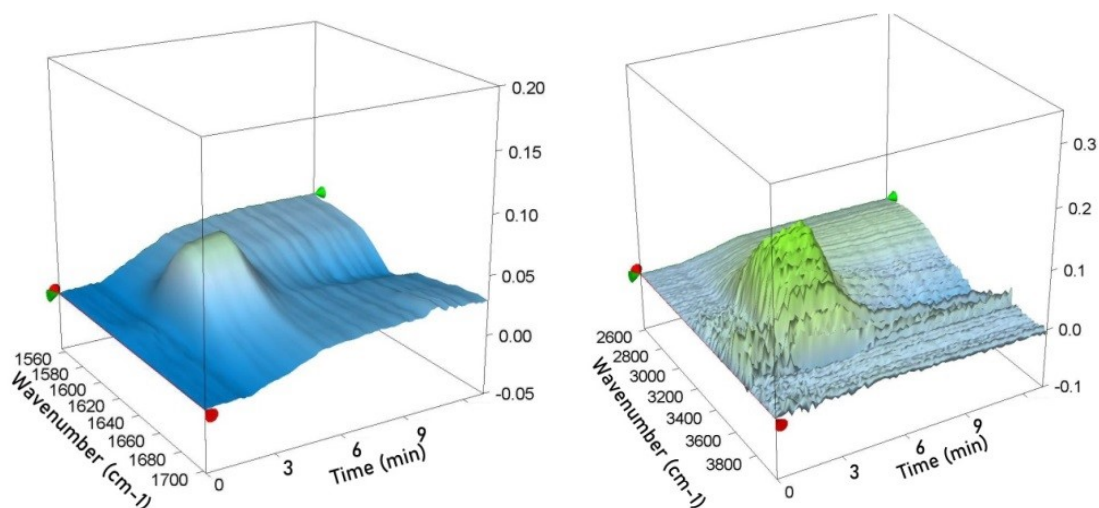
**Figure S27:** FTIR difference spectra of the SiO<sub>2</sub> support during DRM in plasma in the 1900-1300 cm<sup>-1</sup> region as a function of time

## S5.2. Ru/SiO<sub>2</sub> catalyst

In contrast to the SiO<sub>2</sub> support alone, the Ru-loaded SiO<sub>2</sub> catalyst was reduced *in-situ* using H<sub>2</sub>/Ar plasma. Section S5.2.1. contains the spectra recorded during the *in-situ* reduction that preceded the DRM experiment, as referenced in the main paper.

Again, in order to disentangle the effects of the individual reactants of DRM (i.e. CO<sub>2</sub> and CH<sub>4</sub>), we performed experiments with CO<sub>2</sub>/Ar and CH<sub>4</sub>/Ar plasma in addition to experiments with a mixture of the reactants. The experimental procedures are slightly different from the procedures used for DRM, and are discussed, along with presenting the results, in section S5.2.2. and section S5.2.3. for CO<sub>2</sub>/Ar and CH<sub>4</sub>/Ar, respectively.

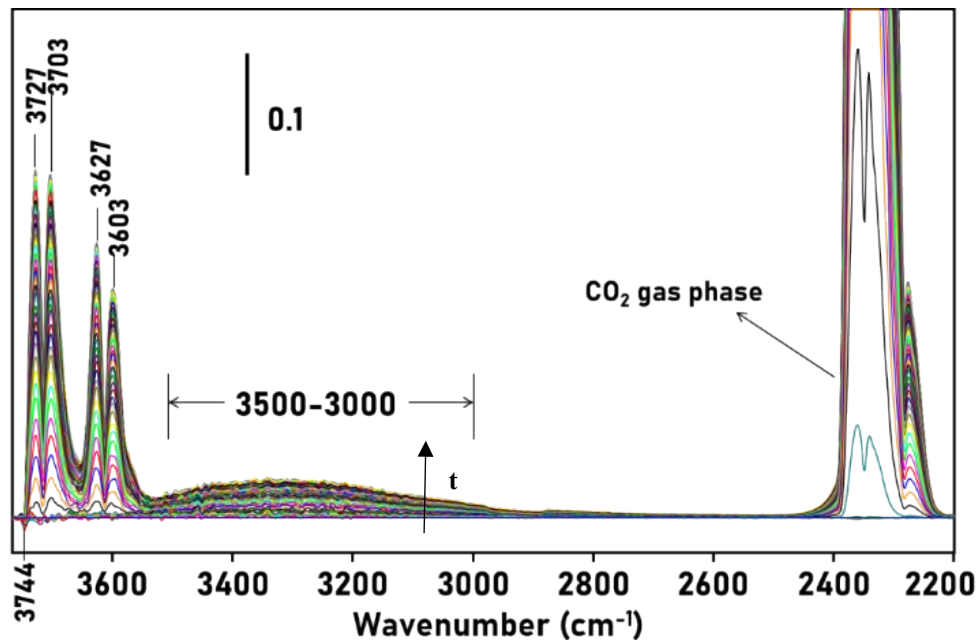
### S5.2.1. H<sub>2</sub>/Ar



**Figure S28:** FTIR spectra in the 1700-1560 (left) and 3900-2600  $\text{cm}^{-1}$  (right) region as a function of time recorded during the *in-situ* reduction of the Ru/SiO<sub>2</sub> catalyst by H<sub>2</sub>/Ar plasma

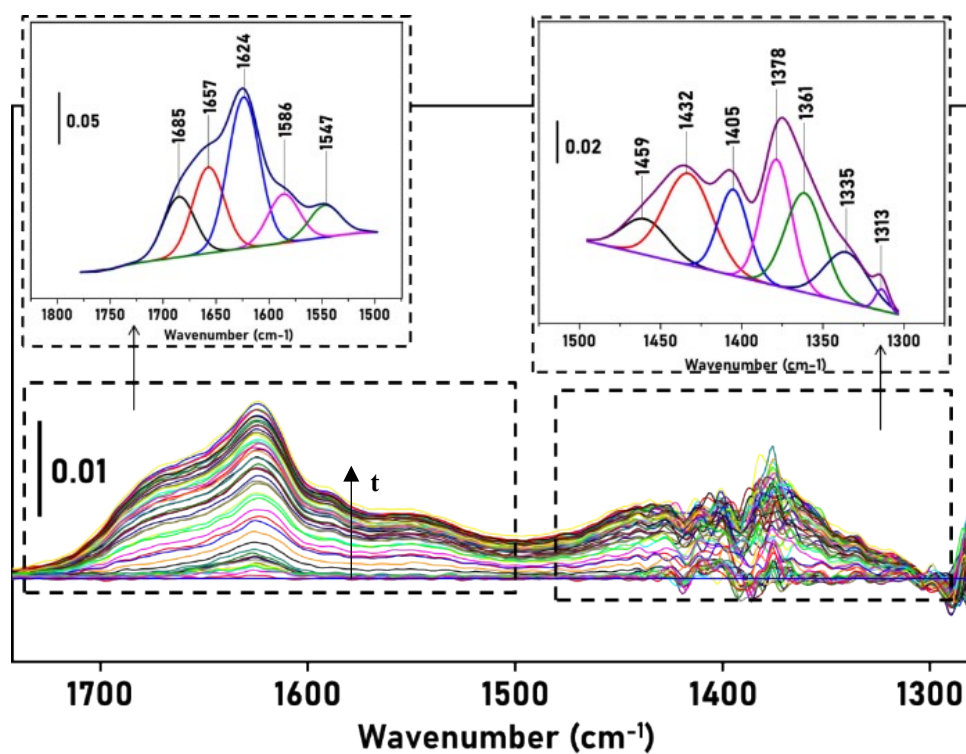
### S5.2.2. CO<sub>2</sub>/Ar

The procedure described in section S5.1.1 was again used for the Ru/SiO<sub>2</sub> catalyst, with the addition of an *in-situ* reduction using H<sub>2</sub>/Ar plasma (20 vol% H<sub>2</sub> and 80 vol% Ar, with a total gas flow rate of 20 mL min<sup>-1</sup> (STP)) at  $\sim 28$  kV for 20 min right after the catalyst activation under vacuum. This reduction was followed by purging the cell under vacuum (0.3 Torr) to remove the water formed during the reduction step, and remove remaining H<sub>2</sub> in the cell.

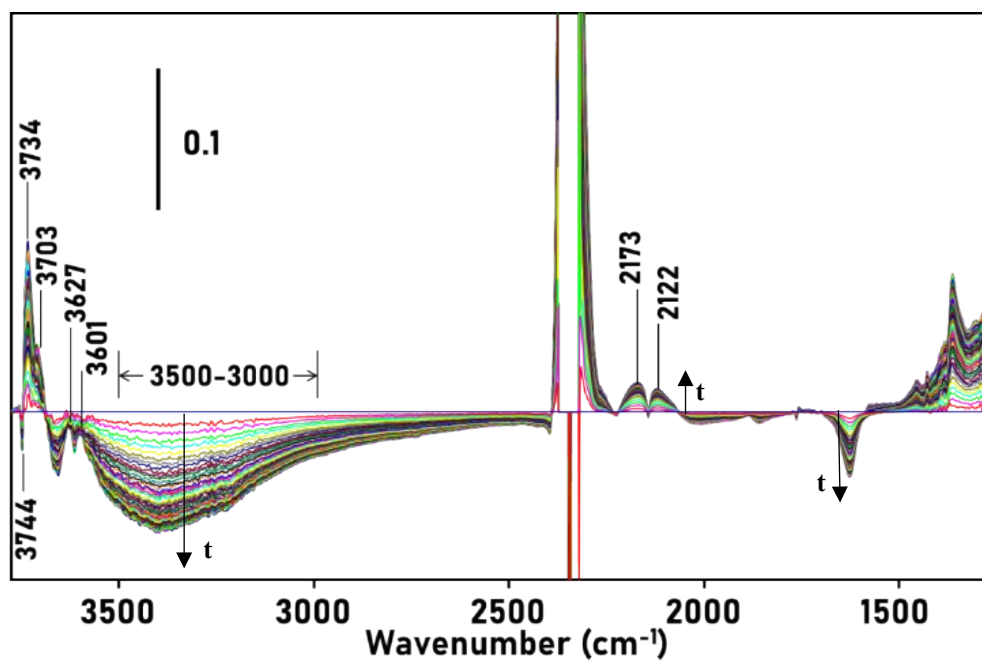


**Figure S29:** FTIR difference spectra of the 3 wt% Ru/SiO<sub>2</sub> catalyst exposed to CO<sub>2</sub>/Ar before plasma ignition in the 3800-2200  $\text{cm}^{-1}$  region as a function of time

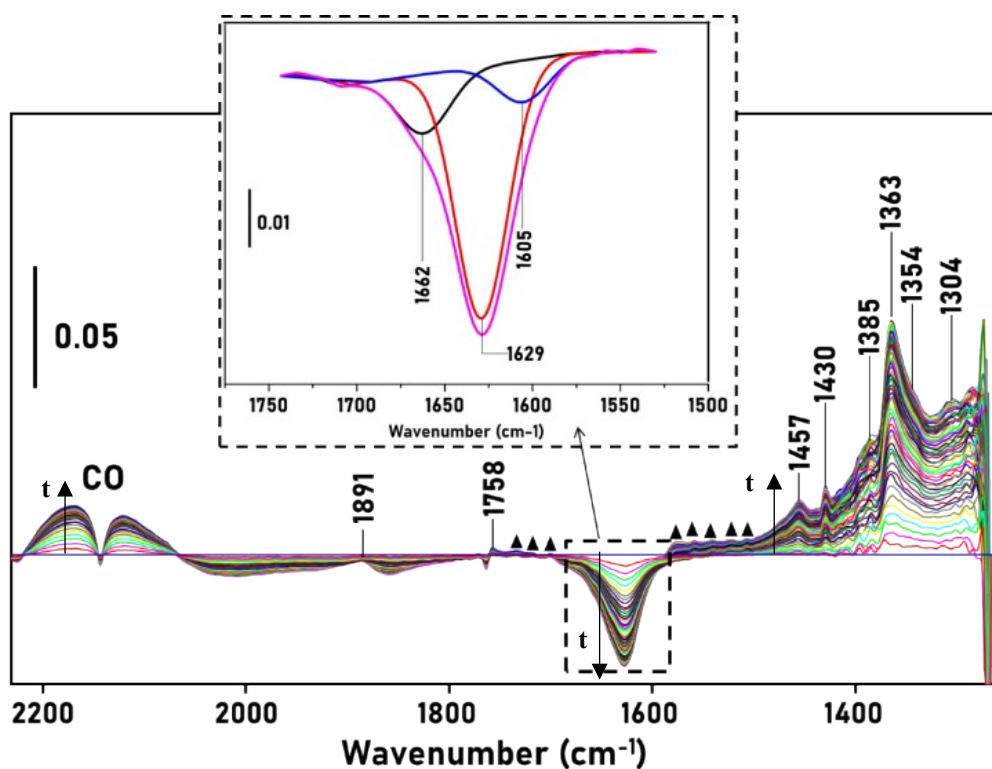




**Figure S30:** FTIR difference spectra of the 3wt% Ru/SiO<sub>2</sub> catalyst exposed to CO<sub>2</sub>/Ar before plasma ignition in the 1750-1275 cm<sup>-1</sup> region as a function of time with details of the 1750-1475 and 1525-1300 cm<sup>-1</sup> regions



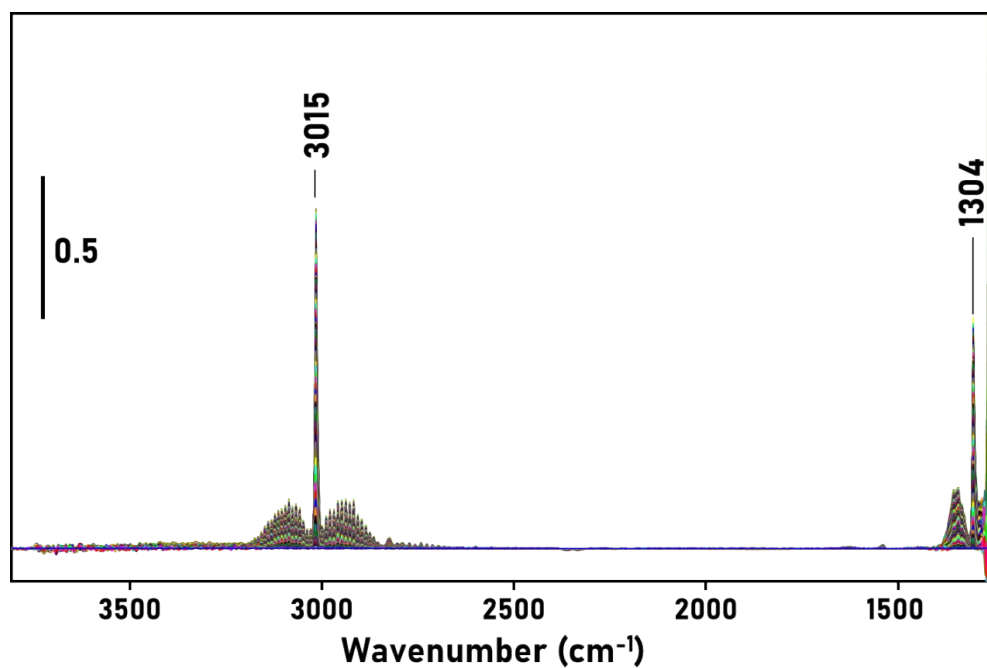
**Figure S31:** FTIR difference spectra of the 3wt% Ru/SiO<sub>2</sub> catalyst exposed to CO<sub>2</sub>/Ar plasma in the 3750-2600 cm<sup>-1</sup> region as a function of time



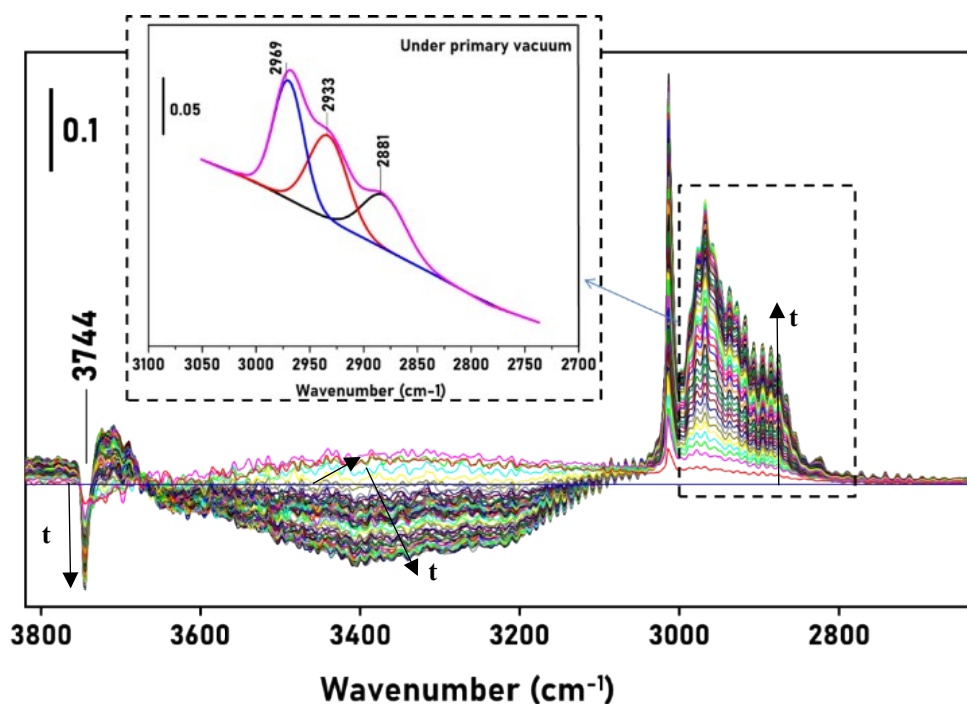
**Figure S32:** FTIR difference spectra of the SiO<sub>2</sub> support exposed to a CO<sub>2</sub>/Ar plasma in the 2220-1250 cm<sup>-1</sup> region as a function of time with detail of the 1750-1525 cm<sup>-1</sup> region at steady state; (▲) indicates bands corresponding to H<sub>2</sub>O vapor

### S5.2.3. CH<sub>4</sub>/Ar

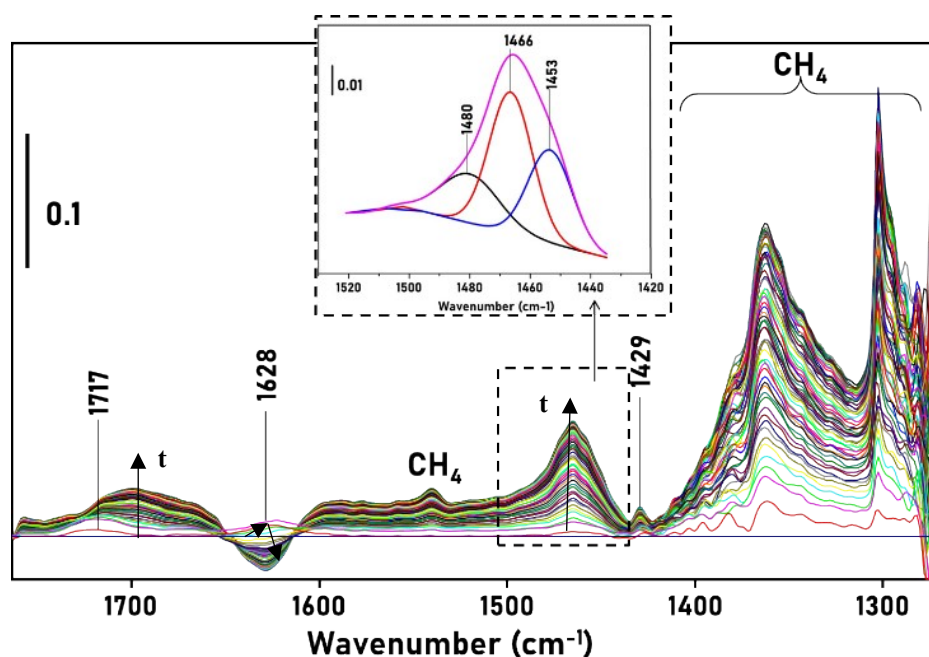
The procedure described in section S5.2.2 was again used, with a gas composition of 7 mL min<sup>-1</sup> (STP) CH<sub>4</sub> and 13 mL min<sup>-1</sup> (STP) Ar.



**Figure S33:** FTIR difference spectra of the 3wt% Ru/SiO<sub>2</sub> catalyst exposed to CH<sub>4</sub>/Ar before plasma ignition in the 3900-1250 cm<sup>-1</sup> region as a function of time



**Figure S34:** FTIR difference spectra of the 3wt% Ru/SiO<sub>2</sub> catalyst exposed to a CH<sub>4</sub>/Ar plasma in the 3800-2600 cm<sup>-1</sup> region as a function of time with detail of the 3075-2750 cm<sup>-1</sup> region under primary vacuum

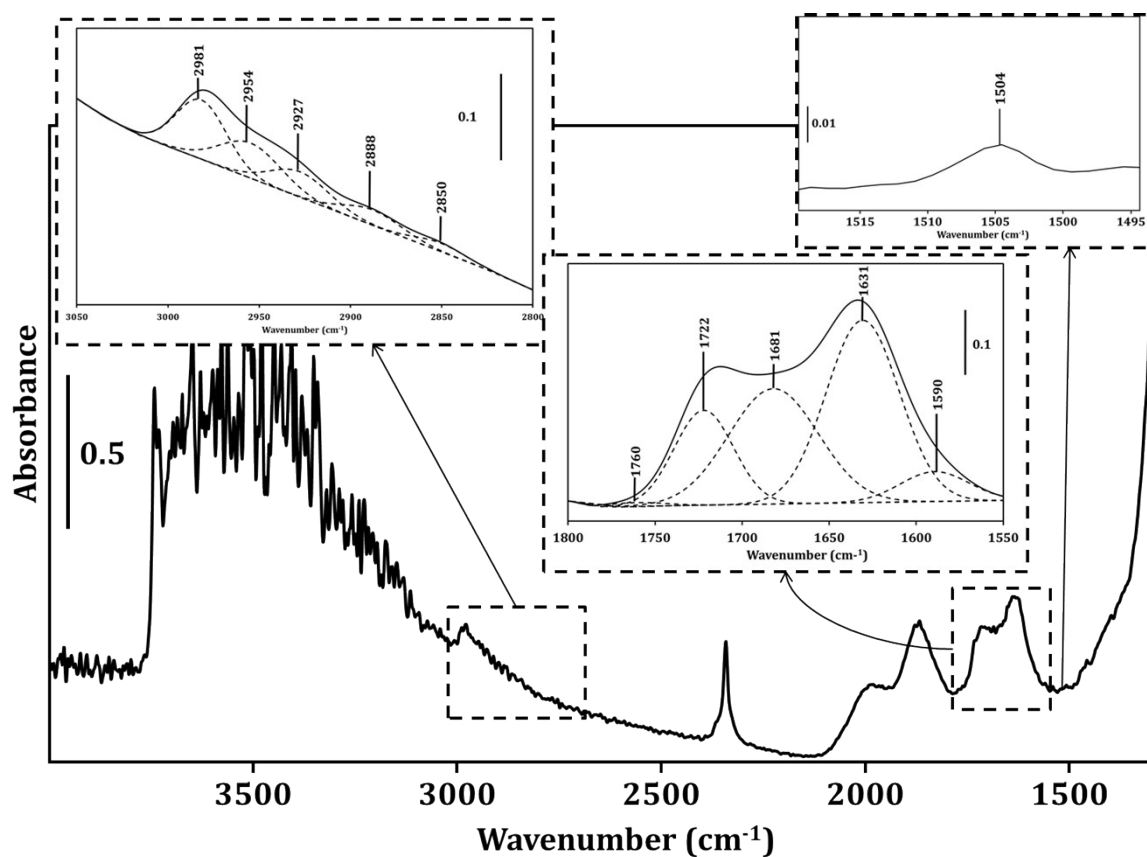


**Figure S35:** FTIR difference spectra of the 3wt% Ru/SiO<sub>2</sub> catalyst exposed to a CH<sub>4</sub>/Ar plasma in the 1775-1275 cm<sup>-1</sup> region as a function of time with detail of the 1520-1435 cm<sup>-1</sup> region

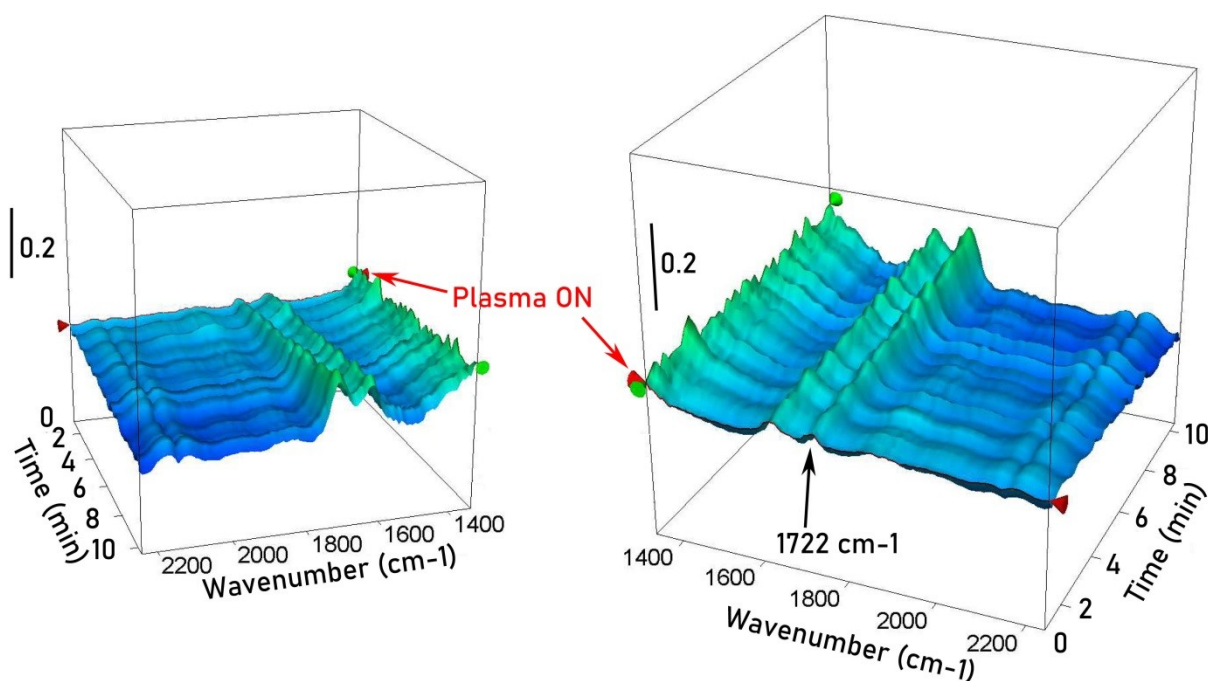
#### S5.2.4. Dry reforming of methane (DRM)

Again, for the DRM experiments, the procedure as described in section 2.2.2 in the main paper was used. Below, relevant results which are referenced in the main paper, and complementary to the results presented there, are shown.





**Figure S36:** FTIR spectrum (4000-1300 cm<sup>-1</sup>) at steady state of the 3wt% Ru/SiO<sub>2</sub> catalyst under vacuum after exposure to CO<sub>2</sub>/CH<sub>4</sub>/Ar plasma



**Figure S37:** FTIR difference spectra of the 3wt% Ru/SiO<sub>2</sub> catalyst during DRM in plasma in the 2200-1400 cm<sup>-1</sup> region as a function of time

### S5.3. Activity measurements in the *in-situ* cell

Below, we show the activity measurements during plasma-assisted DRM over SiO<sub>2</sub> and Ru/SiO<sub>2</sub> in our novel *in-situ* cell (see Table S2). Clearly, while in principle we work under *operando* conditions, as activity can be measured in parallel to our FTIR measurements, the observed conversion of both CO<sub>2</sub> and CH<sub>4</sub> is low, so that we are forced to proceed with activity testing in a different reactor setup, namely a packed bed DBD reactor.

		SiO <sub>2</sub> wafer	3wt%Ru/SiO <sub>2</sub> wafer
CO <sub>2</sub> conversion (%)		0.52 ± 0.05	0.5 ± 0.1
CH <sub>4</sub> conversion (%)		0.73 ± 0.05	0.75 ± 0.05
H <sub>2</sub>	Yield (%)	0.66	0.44
	Selectivity (%)	91 ± 2	59 ± 2
CO	Yield (%)	0.56	0.32
	Selectivity (%)	90 ± 2	50 ± 9
C <sub>2</sub> H <sub>4</sub> (ethylene)	Yield (%)	undetectable	undetectable
	Selectivity (%)	undetectable	undetectable

### S6. Thermal *in-situ operando* IR “sandwich” cell

To distinguish the effect of plasma-induced heating from other plasma effects, the Ru/SiO<sub>2</sub> wafer was also tested in a thermal *in-situ operando* IR “sandwich” cell at 100 and 150 °C (i.e. around the observed temperature range of the catalyst wafer in the plasma, as described in section 3.2.3 of the main paper). More information on the setup and experimental procedure is available below, in addition to the experimental results, which are given in section S6.1. and referenced in the main paper in section 3.2.3.

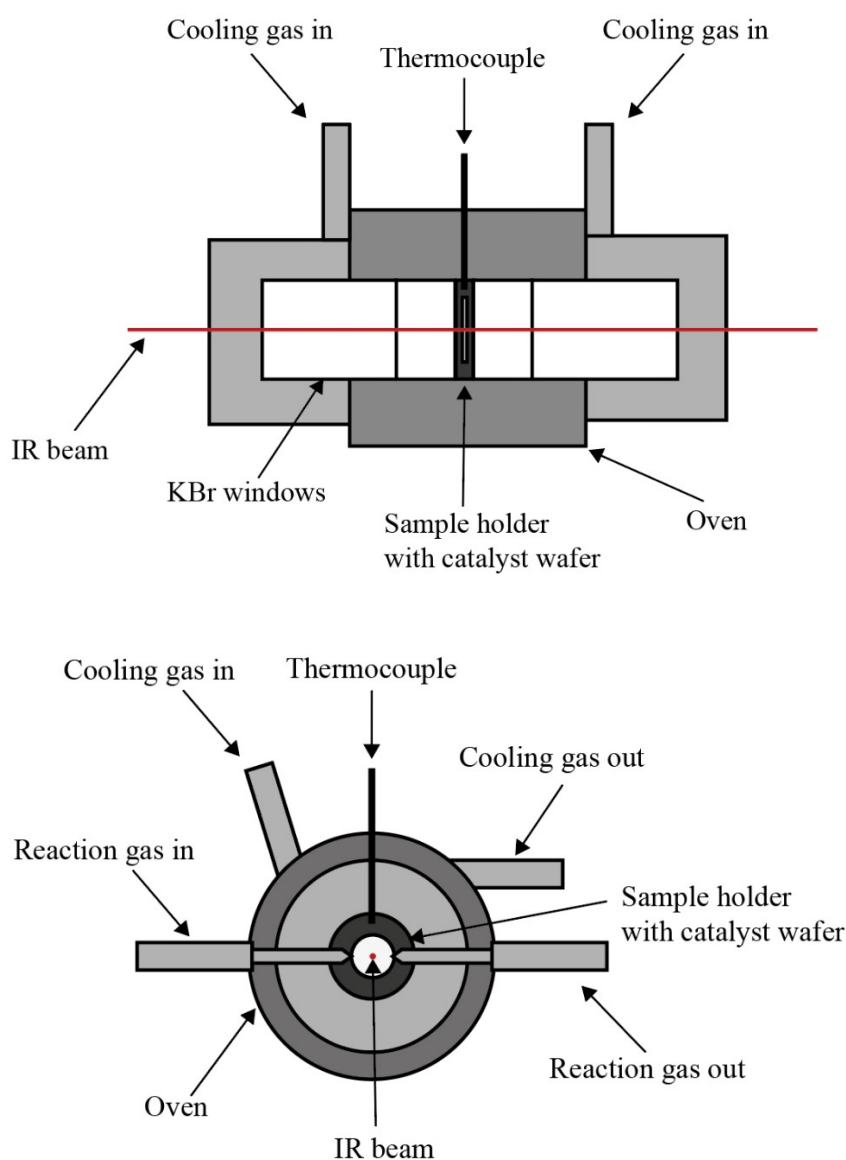
A schematic representation of the thermal *in-situ operando* (or “sandwich” cell **[1]**) is given in figure S38. The H<sub>2</sub>, CH<sub>4</sub>, CO<sub>2</sub> and Ar gas inlet is controlled by four separate Brooks Delta Smart II flow meters, which are operated through a corresponding in-house computer program. The gas inflow is mixed and then introduced directly onto the catalyst wafer via the sample holder, whereas the gas outlet is placed on the opposite side of the sample holder. Additionally, a thermocouple is placed in the sample holder, close to the catalyst wafer, in order to monitor the temperature inside the cell. The sample holder is positioned inside an oven to allow for heating of the catalyst wafer. The *sandwich* cell is positioned inside the sample compartment of a Thermo Fisher scientific Nicolet 6700 spectrometer with a liquid nitrogen cooled mercury-cadmium-telluride (MCT) detector. The sample holder is sealed with four (two on each side) KBr windows for the IR beam to pass through, ensuring an IR transmission window in the 4000-400 cm<sup>-1</sup> range. The catalyst is introduced as a self-supported wafer in the sample holder.

First, the reduced self-supported 3 wt% Ru/SiO<sub>2</sub> wafer was put into the sample holder. Then, the sample holder was introduced into the cell and the catalyst was reduced *in-situ* at 200°C for 1 h in a 20 vol% H<sub>2</sub> and 80 vol% Ar flow (20 mL min<sup>-1</sup> total, STP) after which the cell was cooled down to 25 °C and purged with a 20 mL min<sup>-1</sup> (STP) Ar flow for 1 h.

Afterwards, the reaction mixture (35 vol% CH<sub>4</sub>, 35 vol% CO<sub>2</sub> and 30 vol% Ar; 20 mL min<sup>-1</sup> total, STP) was introduced into the cell. The catalyst wafer inside the cell was subsequently heated stepwise to 50 °C, 75 °C, 100 °C and 150 °C. For each step the temperature of the wafer was kept constant until steady state was reached (after ± 20

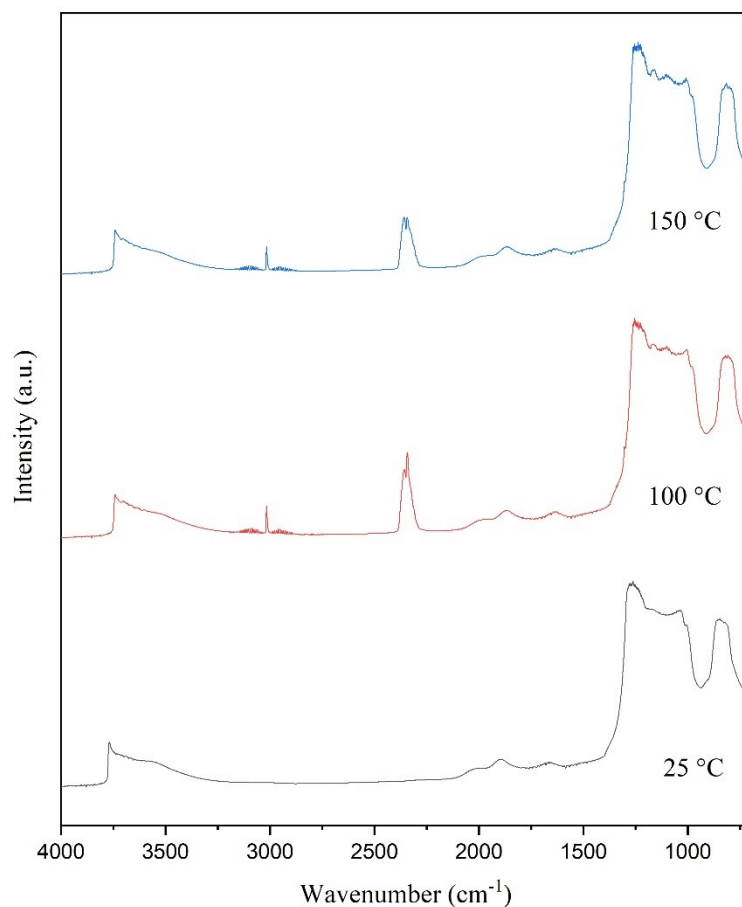
min), after which the temperature was increased to the next step at a heating rate of 3 °C/min.

The catalyst surface (and gas above the surface) was continuously monitored during the DRM reaction using transmission FTIR in the 4000-700  $\text{cm}^{-1}$  range with a resolution of 4  $\text{cm}^{-1}$  (64 scans per spectrum; 1 spectrum per 5 min). The background spectrum was recorded prior to the introduction of the sample holder with catalyst. The spectrometer was operated using OMNIC software. The results are shown in Figure S39.



**Figure S38:** Schematic representation of the front (a) and side (b) view of the thermal *in-situ operando* cell; The cooling gas outlets and reaction gas in- and outlet are perpendicular to the drawing in (a) and thus not illustrated

### S6.1. Thermal DRM *operando* IR study

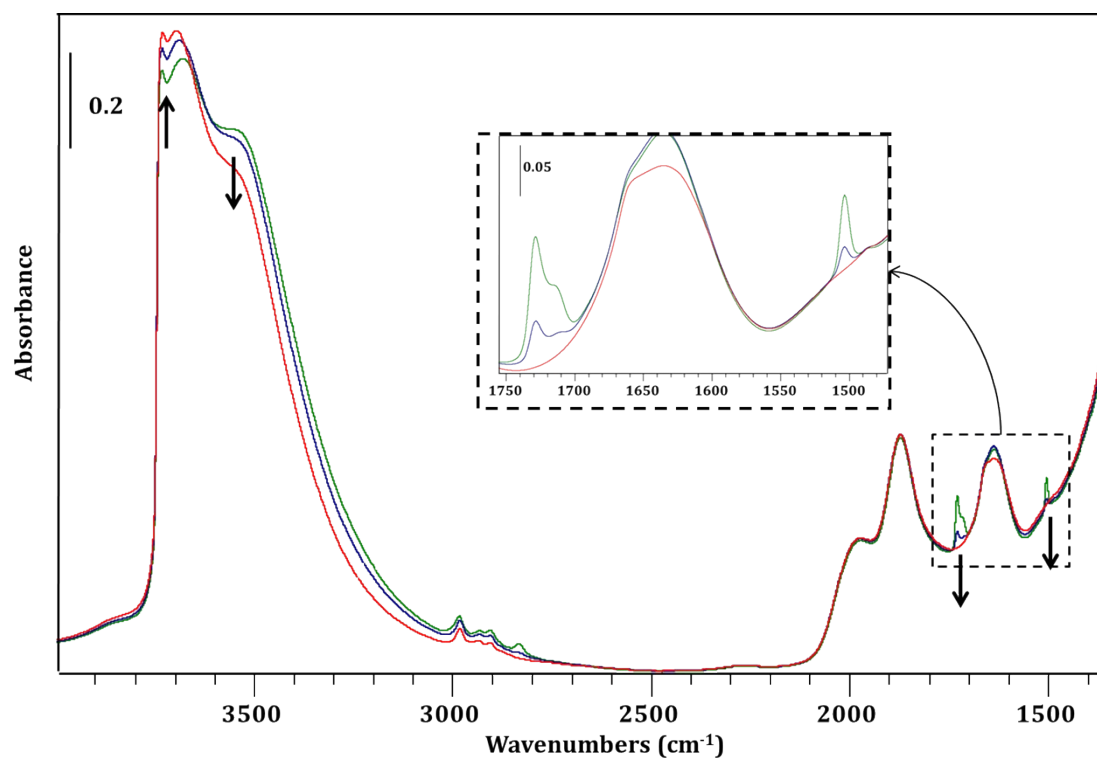


**Figure S39:** Steady state FTIR spectra (4000-700  $\text{cm}^{-1}$ ) of the 3 wt% Ru/SiO<sub>2</sub> sample at 25 °C before gas dosing (black) and exposed to a 1:1 CH<sub>4</sub>/CO<sub>2</sub> gas mixture in Ar at 100 °C (red) and 150 °C (blue)

Figure S39 clearly shows that at the catalyst surface temperatures observed in the plasma (100-150 °C), no additional bands, representing surface species on the catalyst, are observed, and that no CO is formed. Hence, the formation of surface species and the conversion of CO<sub>2</sub> and CH<sub>4</sub> cannot be attributed to plasma-induced surface heating, but must be due to other plasma-effects such as the adsorption of plasma-generated radicals or molecules, or the occurrence of Eley-Rideal reactions.

### S7. Adsorption/desorption of formaldehyde on SiO<sub>2</sub>

In order to strengthen the assignment of the band at 1722  $\text{cm}^{-1}$  which we observed during plasma-catalytic DRM on SiO<sub>2</sub>, we exposed a SiO<sub>2</sub> sample to formaldehyde, and monitored the desorption behaviour as a function of temperature. Prior to infrared measurements, SiO<sub>2</sub> was activated under secondary vacuum at 200 °C during 1 h. Small formaldehyde volume doses of 2.617 mL were sent to the sample until complete saturation at room temperature (23 °C). The saturation was reached at 240  $\mu\text{mol/g}$  of CH<sub>2</sub>O.



**Figure S40:** FTIR spectra of physisorbed formaldehyde on SiO<sub>2</sub> at room temperature and ambient pressure (green), after 5 min exposure to secondary vacuum at room temperature (blue) and after 5 min exposure to secondary vacuum at 125 °C (red) in the 4000-1300 cm<sup>-1</sup> region

## References

1. Wuttke, S.; Bazin, P.; Vimont, A.; Serre, C.; Seo, Y. K.; Hwang, Y. K.; Chang, J. S.; Ferey, G.; Daturi, M., Discovering the active sites for C3 separation in MIL-100(Fe) by using operando IR spectroscopy. *Chemistry* **2012**, *18* (38), 11959-67.